

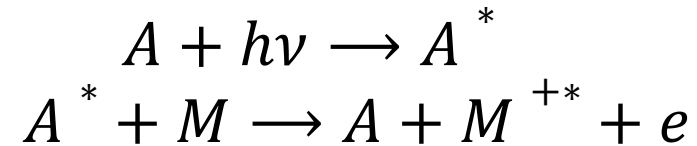
ELECTRONS EMISSION OF FROM COLD CATHODES IN A GAS
DISCHARGE AND ITS INFLUENCE ON CURRENT-VOLTAGE
CHARACTERISTICS

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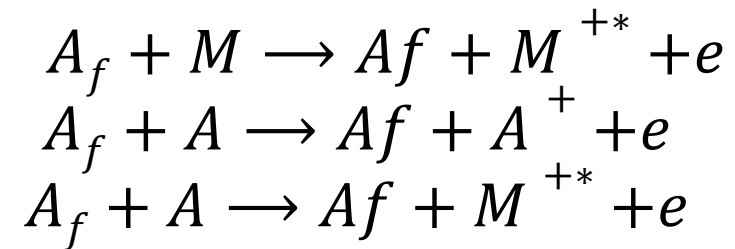
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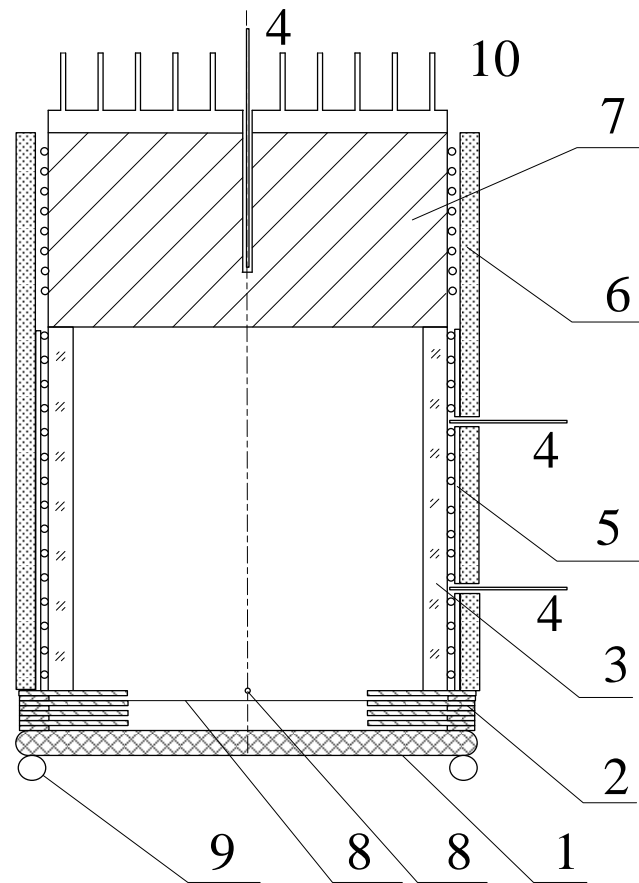
The mechanisms of electron emission in a gas discharge are still the subject of debate. The author's concept is that emission properties are determined by a modified surface layer of cold cathodes. The modification consists in its saturation with particles of the working gas to a density comparable to the packing density of particles in a liquid working gas [O. V. Dudka, et al. *Tech. Phys. Lett.* **39**, 960 (2013)]. As a result of the modification under the influence of fast heavy particles accelerated in the region of the cathodic potential drop and VUV resonance photons, various emission mechanisms are realized upon discharge in noble gases and molecular gases. In turn, the emission mechanism in light and heavy noble gases also varies.

In helium and neon, fast atoms A_f and ions produce mainly the excitation of embedded atoms. Excited atoms in the Penning process ionize the atoms of the matrix, which leads to the appearance of a fast electron emitted from the cathode (Auger effect):



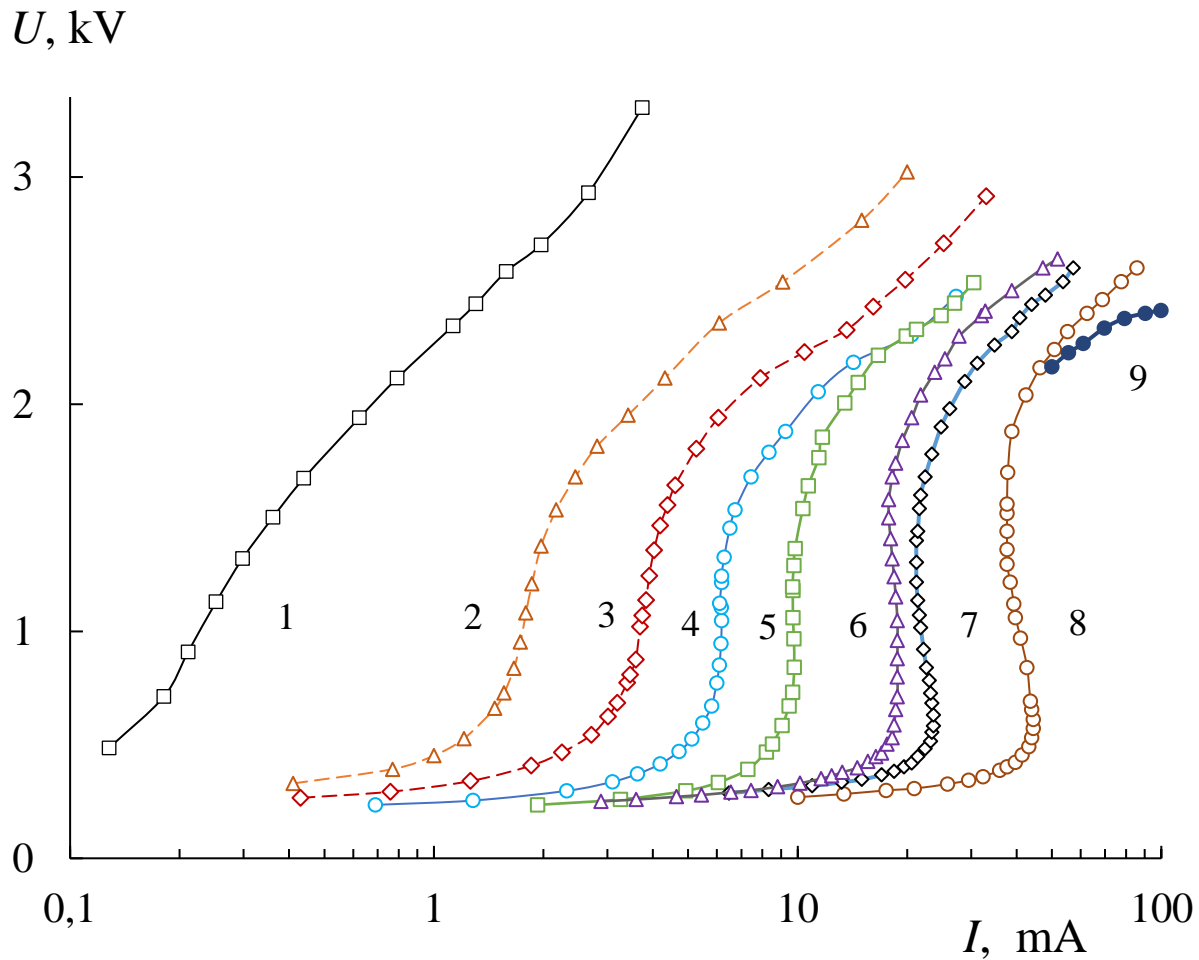
Heavy noble gases with high efficiency produce both excitation with the subsequent Auger effect, and ionization with the release of an electron:





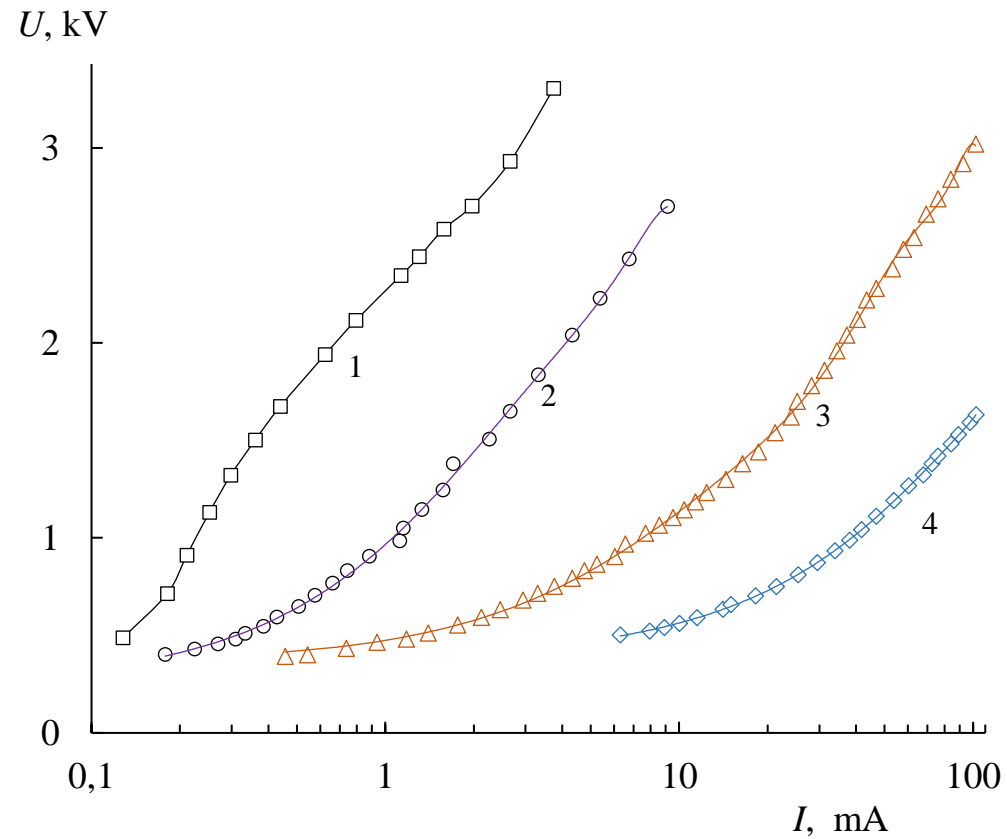
Design of the gas-discharge cell: (1) *Ti* - cathode $d=12\text{mm}$, (2) insulator, (3) drift tube $L=20\text{mm}$, (4) thermocouple, (5) copperplates, (6) heat insulator, (7) anode (collector), (8) probes, (9) water cooling system, and (10) heat radiator.

This cell makes it possible to measure current-voltage characteristics and electron beam generation efficiency



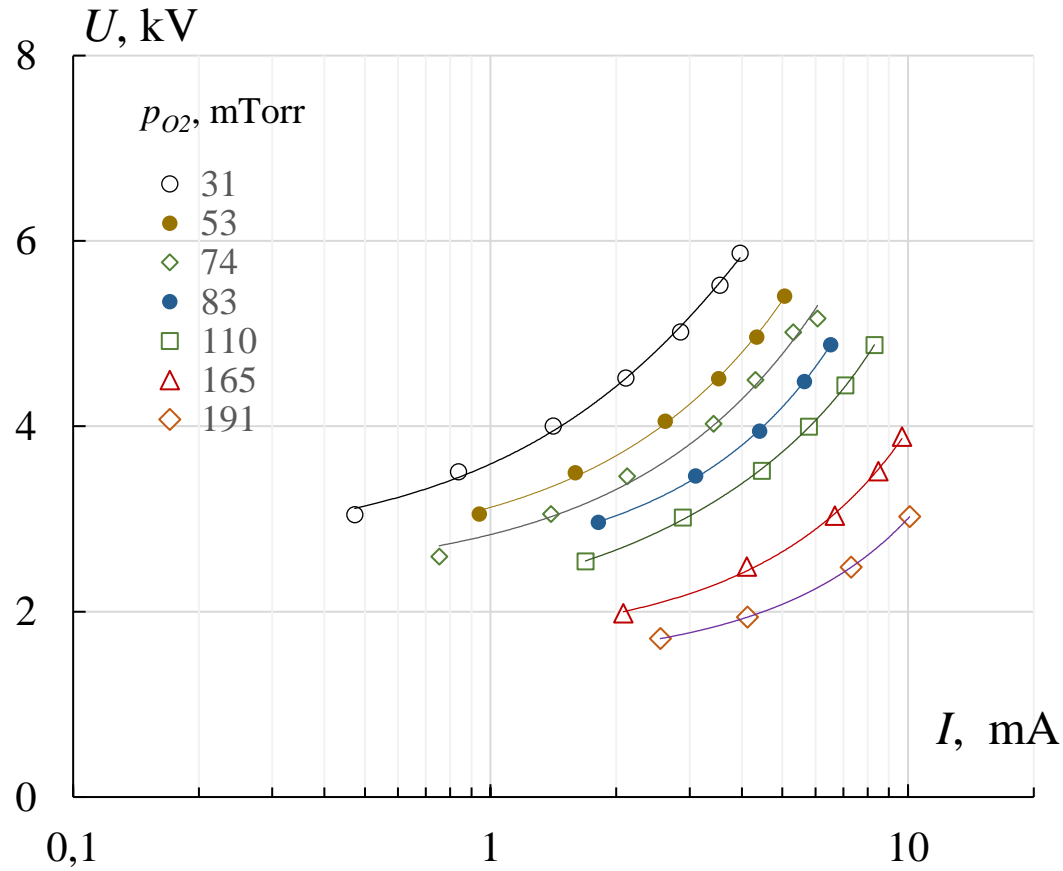
Current-voltage characteristics of continuous (1–8) and quasi-continuous (9) discharges in *He* at $p_{He} = (1) 4, (2) 6, (3) 8, (4) 10, (5) 12.5, (6) 16, (7) 20,$ and $(8, 9) 28$ Torr.

Absolute value of the current density j at $p_{He}=28$ Torr and $U=2.4$ kV is ~ 275 times lower than that calculated for $j=2.5 \times 10^{-12} p_{He}^2 U^3$ [A/cm²], where p_{He} [Torr] - pressure of helium; U [V] is the cathodic potential drop [K. A. Klimenko et al. Sov. Phys. Tech. Phys. **35**, 1084 (1990).]

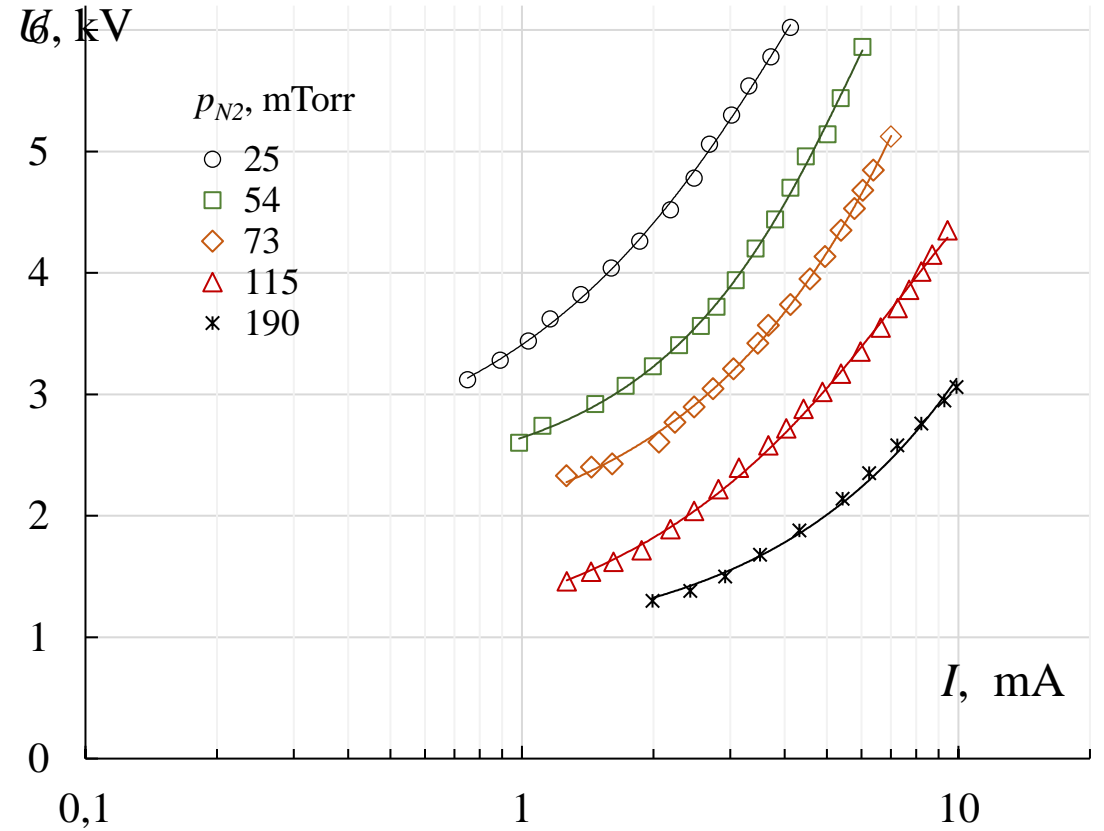


Current-voltage characteristics of continuous discharges in pure He (1) and $He-O_2$ mixtures (2–4) at $p_{He} = (1-4)$ 4 Torr and $p_{O_2} = (2)$ 8, (3) 25, and (4) 65 mTorr.

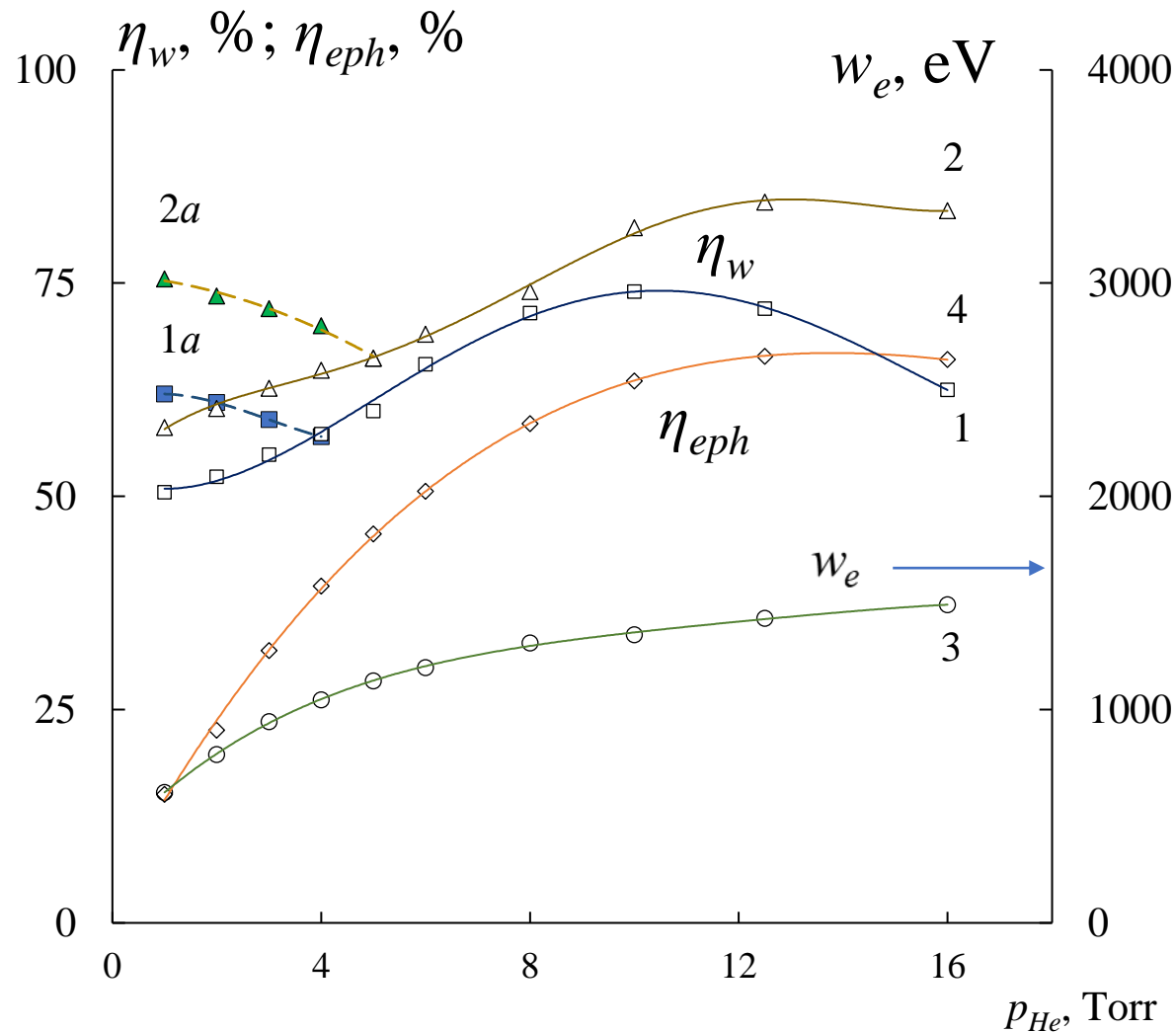
Only at O_2 admixture $\sim 1.6\%$ current-voltage characteristics became comparable with relation $j=2.5 \times 10^{-12} p_{He}^2 U^3$ [A/cm²].



Current-voltage characteristics of continuous discharges in O_2 at $p_{O_2} = 31; 53; 74; 83; 110; 165$ and 191 mTorr.



Current-voltage characteristics of continuous discharges in N_2 at $p_{N_2} = 25; 54; 73; 115$ and 190 mTorr.



In pure *He* photoemission prevails

EB generation efficiency η_w in pure *He* (1,2) and *He-O₂* mixtures (1a,2a) at $p_{O_2}=15$ mTorr as a function of the helium pressure p_{He} .

Curve 3 shows the energy w_e which dissipated by one fast electron in the drift space,

Curve 4 shows the fraction of photoelectric current η_{eph} in the discharge current at $U = 2.5$ (1,1a,3,4) and 3.5 kV. (2,2a)

$$n_{eph} = \eta_{ex} w_e \gamma_{ph} R / h\nu$$

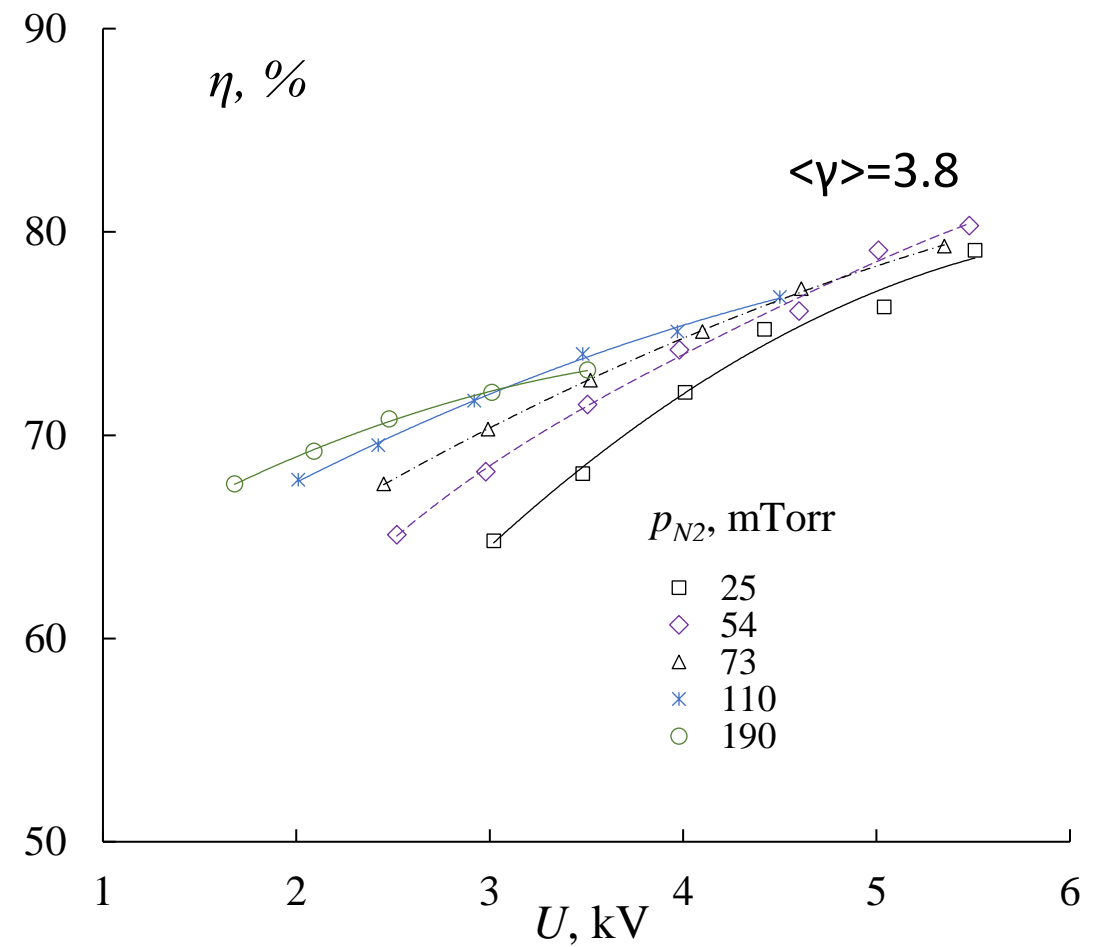
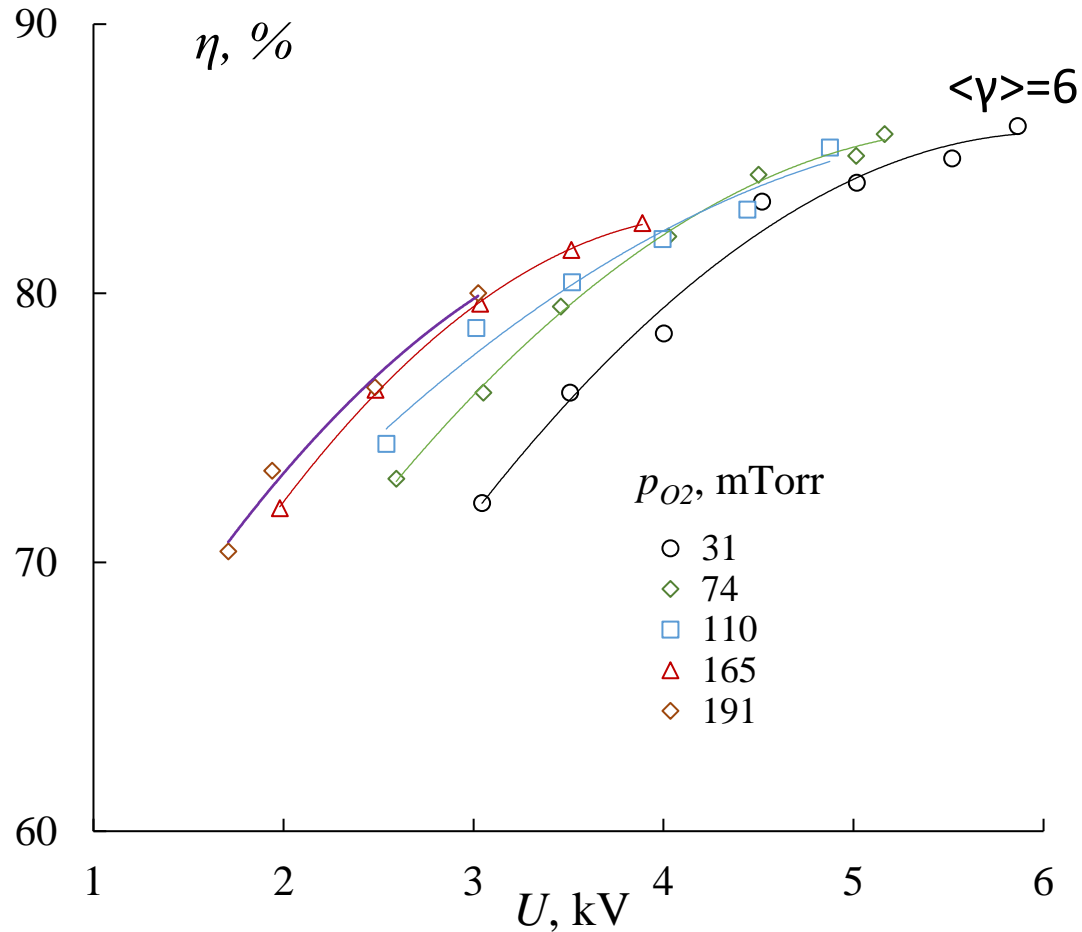
n_{eph} the number of photoelectrons emitted as a result of deceleration of EB - electron in the DS

$\eta_{ex}=0.3$ the fraction of the EB energy contributed to excite the resonance states

$R=0.17$ the fraction of the vacuum UV radiation intercepted by cathode

$\gamma_{ph}=0.3$ the photoemission coefficient

EB generation efficiency η_w in O_2 (a) and N_2 (b) as functions of the voltage U



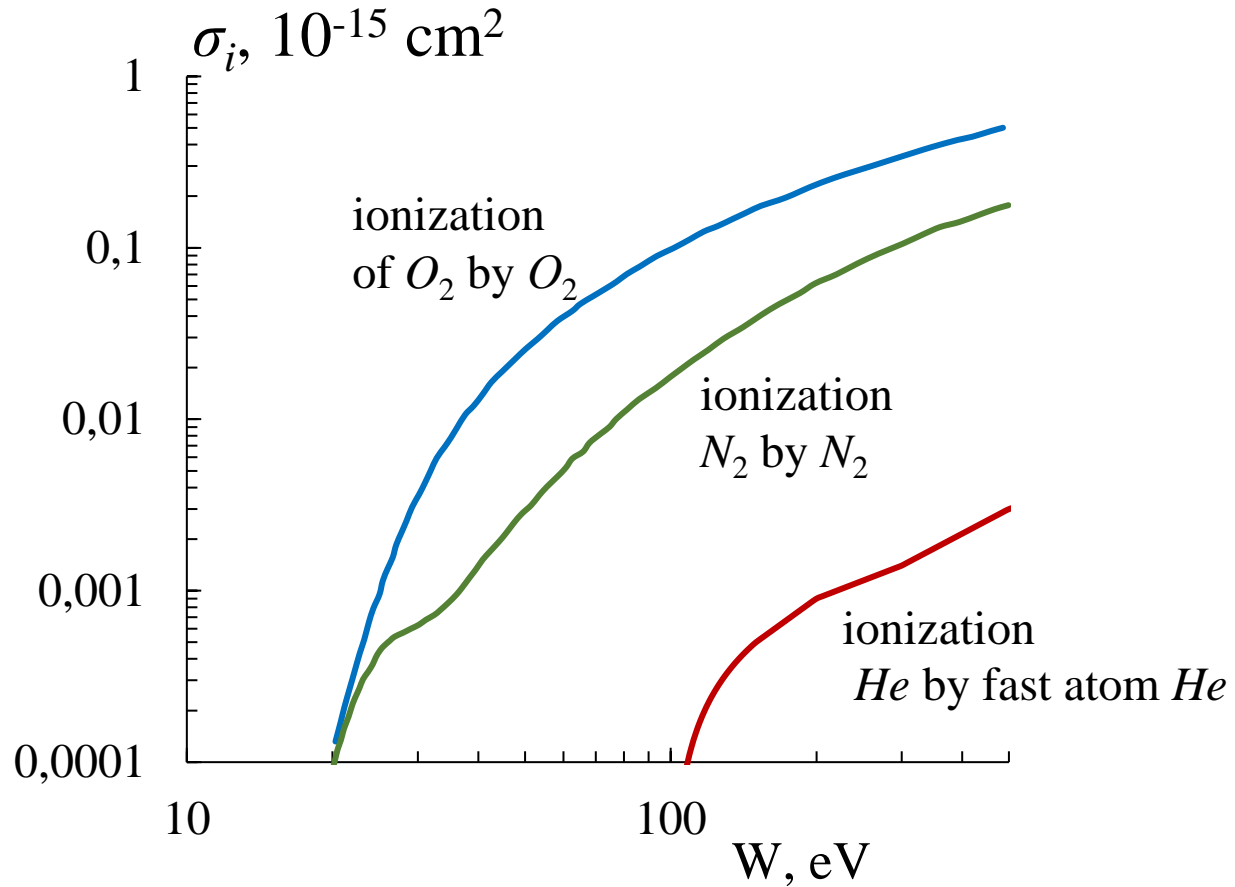
$$\eta = \frac{\langle \gamma \rangle}{\langle \gamma \rangle + 1}$$

γ_i – emissive coefficient under action of molecular ions,
 $\sum \gamma_m$ – emissive coefficient due to fast molecules.

$$\langle \gamma \rangle = \gamma_i + \sum \gamma_m$$

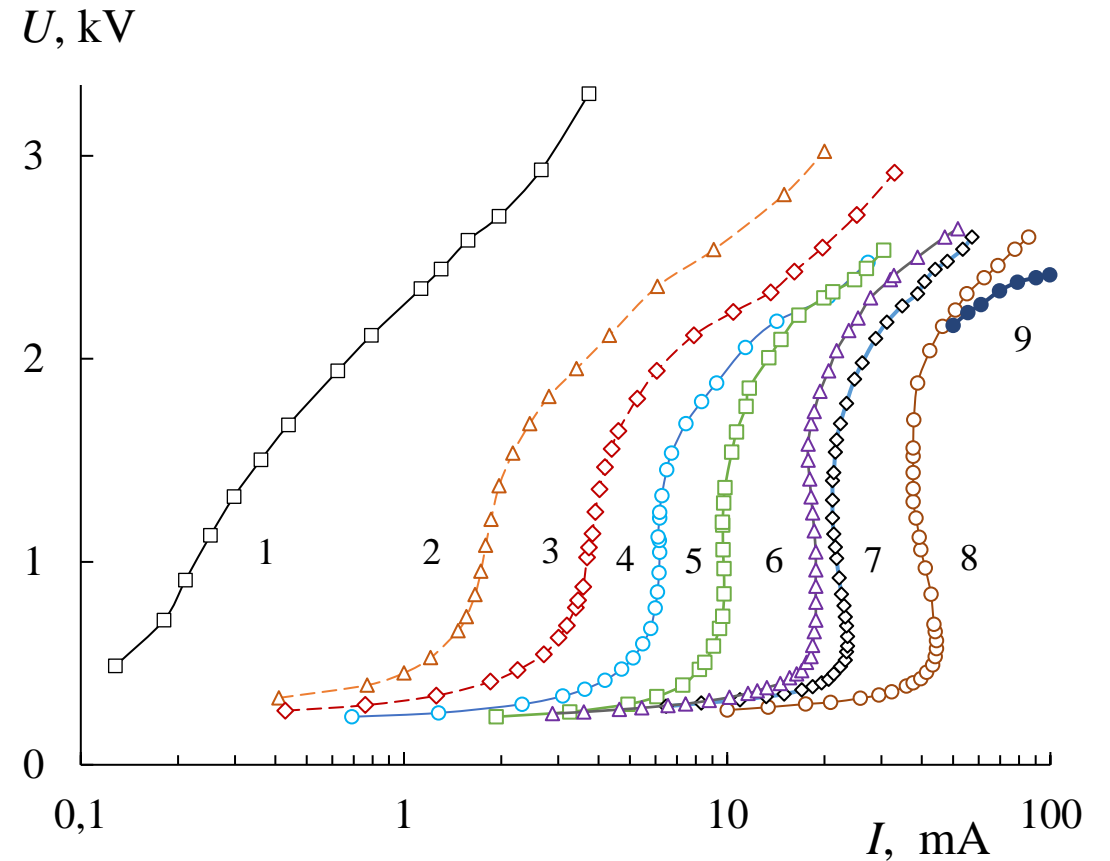
In O_2 and N_2 emission under bombardment by heavy particles prevails

Discussion

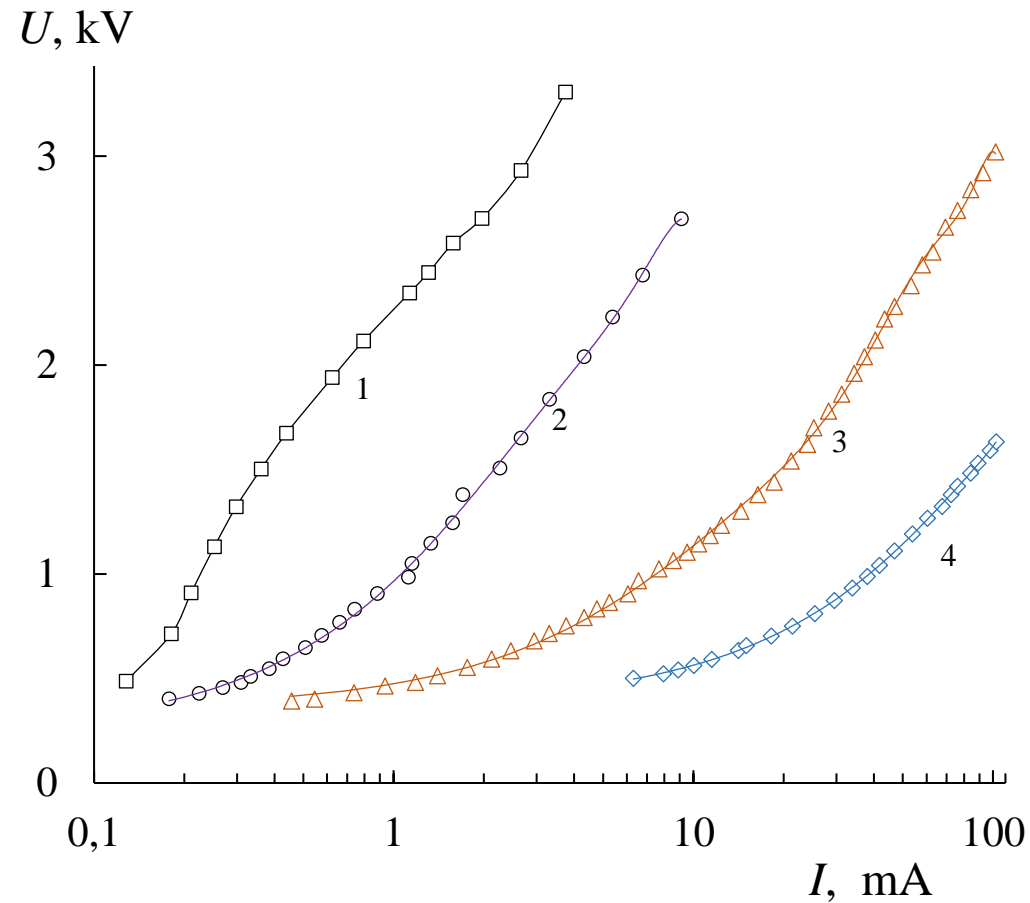


Cross sections for ionization of atoms by fast atoms as functions of the colliding particles energy

$w=500\text{eV}, \gamma=4.1 \times 10^{-1}$ for N_2 [Utterback, 1961]
 $\gamma=3 \times 10^{-3}$ for He [Lakits, 1990]



CVC of discharge in He at $p_{He} = (1) 4, (2) 6, (3) 8, (4) 10, (5) 12.5, (6) 16, (7) 20, \text{ and } (8, 9) 28 \text{ Torr}$.



Current-voltage characteristics of continuous discharges in pure He (1) and $He-O_2$ mixtures (2–4) at $p_{He} = (1-4)$ 4 Torr and $p_{O_2} = (2)$ 8, (3) 25, and (4) 65 mTorr.

$He^+ + O_2 \rightarrow O_2^+ + He$. Oxygen ions are accelerated in the cathode fall region CFR up to energy closely to $w_i = eU_c$. O_2^+ has much higher γ in comparison with He^+ . In addition O_2^+ effectively ionizes He in the CFR

Conclusion

The experimental studies of gas discharges in pure He, O₂, N₂, and He–O₂(N₂) have shown that the purity of He has a strong effect on the discharge characteristics. Under insufficiently pure (in fact, uncontrolled) conditions of technical vacuum, different shapes of the CVC can take place. Therefore, the mechanisms sustaining the discharge and responsible for EB generation cannot be reliably analyzed under these conditions.

In pure helium $p > 4\text{Torr}$ and $U > 1.5\text{ kV}$, the current caused by cathode photoillumination from the space between the cathode and the anode, where most energy of the electrons accelerated in the cathode sheath is dissipated. Under these conditions, the energy efficiency of EB generation reaches a high value (up to 85%) at a low cathode sputtering and the shape of the CVC differs substantially from those previously observed by other authors.

In pure O₂ and N₂, kinetic emission is the main source of electrons in the discharge. Due to the high value of $\langle\gamma\rangle$ under bombardment by heavy particles highly efficient EB generation was achieved in O₂ and N₂, with efficiencies of 86 and 80%, respectively. However, the sputtering of the cathode under these conditions is much stronger than in a discharge in pure He.

Thank you for the attention